IN THE SPECIFICATION

Please add the following beginning at page 6, line 22.

AI

In one embodiment, a nitride liner layer is formed on the CVD material layer in the CVD apparatus to a thickness of approximately 30Å to 100Å. A trench filling layer is then formed on the nitride liner layer in the CVD apparatus to a thickness of approximately 3000Å to 10000Å.

Please add the following begining at page 7, line 23 of the specification.

Fig. 15 is a graph showing the effects of the present invention.

AZ